



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 5520**  
Hiroki MAEDA et al. : Attorney Docket No. 2006\_0043A  
Serial No. 10/565,104 : Group Art Unit 1795  
Filed January 19, 2006 : Examiner Anca Eoff  
PHOTOSENSITIVE RESIN COMPOSITION : **Mail Stop: RCE**  
AND METHOD OF FORMING A PATTERN  
USING THE COMPOSITION

THE COMMISSIONER IS AUTHORIZED  
TO CHARGE ANY DEFICIENCY IN THE  
FEES FOR THIS PAPER TO DEPOSIT  
ACCOUNT NO 23-0975

---

**SUBMISSION UNDER 37 CFR 1.114**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the Final Rejection dated March 31, 2008, please amend the present application as follows: